

(19) World Intellectual Property
Organization
International Bureau



(43) International Publication Date
26 May 2005 (26.05.2005)

PCT

(10) International Publication Number
WO 2005/047170 A1

(51) International Patent Classification⁷: B67D 1/07

(21) International Application Number:
PCT/NL2004/000799

(22) International Filing Date:
15 November 2004 (15.11.2004)

(25) Filing Language: Dutch

(26) Publication Language: English

(30) Priority Data:
1024787 14 November 2003 (14.11.2003) NL

(71) Applicant (for all designated States except US): SARA
LEE/DE N.V. [NL/NL]; Keulsekade 143, NL-3532 AA
Utrecht (NL).

(72) Inventor; and

(75) Inventor/Applicant (for US only): KROON, Arie
[NL/NL]; Zakedijkje 34, NL-1862 HB Bergen (NL).

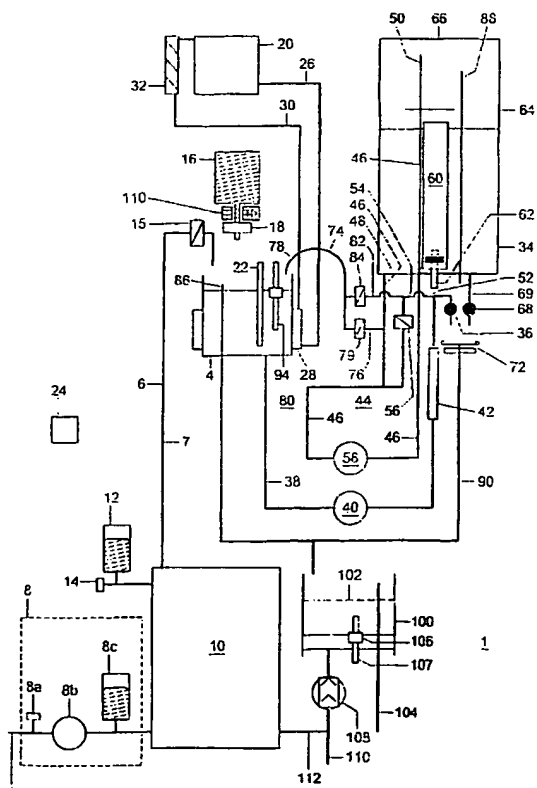
(74) Agent: WINCKELS, J., H. F.; Nieuwe Parklaan 97,
NL-2587 BN Den Haag (NL).

(81) Designated States (unless otherwise indicated, for every
kind of national protection available): AE, AG, AL, AM,
AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN,
CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI,
GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE,
KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD,
MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG,
PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM,
TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM,
ZW.

(84) Designated States (unless otherwise indicated, for every
kind of regional protection available): ARIPO (BW, GH,
GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM,
ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM),
European (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI,
FR, GB, GR, HU, IE, IS, IT, LU, MC, NL, PL, PT, RO, SE,
SI, SK, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ,
GW, ML, MR, NE, SN, TD, TG).

[Continued on next page]

(54) Title: WATER SUPPLY APPARATUS AND CLEANING SYSTEM FOR CLEANING THE WATER SUPPLY APPARATUS



(57) Abstract: A cleaning system designed for cleaning a wa-
ter supply apparatus wich is provided with :a tap water inlet
(2);a mineral dosing ubtil unit(18) with the aid of which,on the
basis of tap water ,mineral water can be generated; water pro-
cessing means and a control unit(24) designed for controlling at
least a part of the water processing means according to a prede-
termined water processing program for the purpose of present-
ing mineral water ,the cleaning system being provided with at
least one cleaning agent vessel (H) from which ,in use ,cleaning
agent can be supplied ,directly or indirectly,to the water sup-
ply apparatus , wherein the cleaning system is provided with
a cleaning system control unit designed for controlling at least
a part of the water processing means according to a predeter-
mined cleaning program for the purpose of a cleaning at least a
part of the water processing means.

VO 2005/047170 A1

WO 2005/047170 A1



Published:

— with international search report

For two-letter codes and other abbreviations, refer to the "Guidance Notes on Codes and Abbreviations" appearing at the beginning of each regular issue of the PCT Gazette.